

EC21101: Basic Electronics

Instructors:

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Course webpage (Sec. 4):

<https://sites.google.com/site/dseniitkharagpur/be2016s4>
&

Register in usebackpack.com, search for the course (Basic Electronics - Section 4) page and join using the code: 0d11ef

Class Timings @ F102, EECE Building:

Monday 10.00 am – 10.55 am

Tuesday 8.00 am – 9.55 am (with a 5 min break in between)

Thursday 10.00am – 10.55am (class /tutorial)

Office Hours:

[Thursday](#) – 3 to 5pm

(Room A111, EECE Building)

Syllabus:

- Semiconductor Materials and Diodes
- Diode Circuits
- The Bipolar Junction Transistor
- Basic BJT Amplifiers
- The Field-Effect Transistor
- Basic FET Amplifiers
- Ideal Operational Amplifiers and Op-Amp Circuits
- Digital Electronics

Detailed in Course Webpage or usebackpack.com

Books :

Text Book -

- [Microelectronics: Circuit Analysis and Design](#) by Donald A. Neaman

Reference Books -

- [Microelectronic Circuits](#) by Adel S. Sedra and Kenneth C. Smith
- [Microelectronics](#) by Jacob Millman and Arvin Grabel
- [Fundamentals of Microelectronics](#) by Behzad Razavi
- [Electronic Devices and Circuit Theory](#) by Robert L. Boylestad and Louis Nashelsky

Evaluation Process:

Mid-Semester Examination : 30 Marks

End-Semester Examination: 50 Marks

TA: 20 Marks

- Class Tests (14 marks)

- Tutorial (3 marks)

- Attendance (3 marks)

Technical queries:

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Semiconductor Materials and Properties

GOAL:

- Two types of charged carriers exist in a semiconductor
- Two mechanisms that generate currents in a semiconductor

Semiconductor:

Conductor - Materials that support generous flow of charge (electron) when a finite voltage is applied across two terminals.

Insulators - Materials that allow **very little conductivity** even when under severe pressure from an applied voltage source.

Semiconductors - In between Conductor and Insulator

Intrinsic Semiconductor:

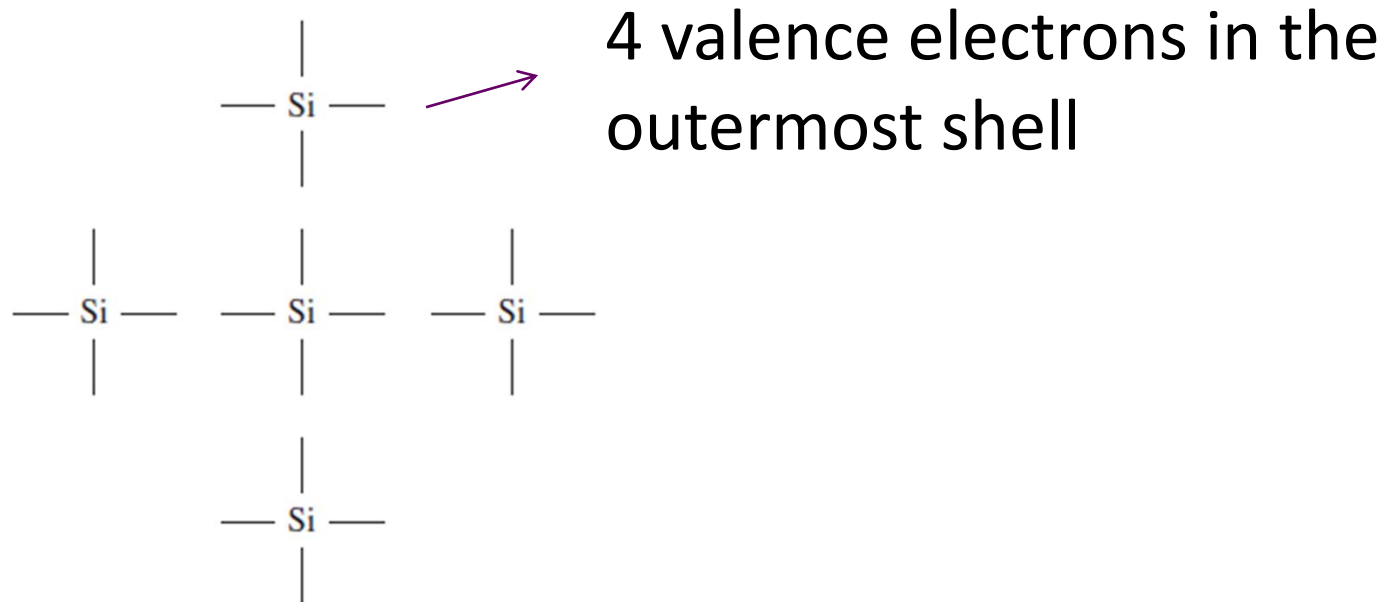
Atomic structure – Atoms have negatively charged electrons **orbiting** around nucleus having positively charged protons and neutral neutrons

- The **electrons** are distributed **in various shells** at different mean distance from the nucleus.
- Electron **energy increases** with **increase in the distance**.
- Hence, the **outermost shell** has electrons with **highest energy** and are called the **valence electrons**

Example –

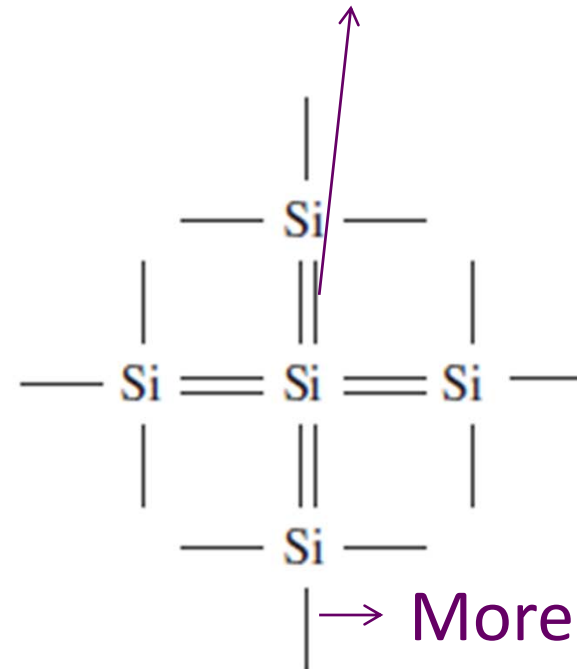
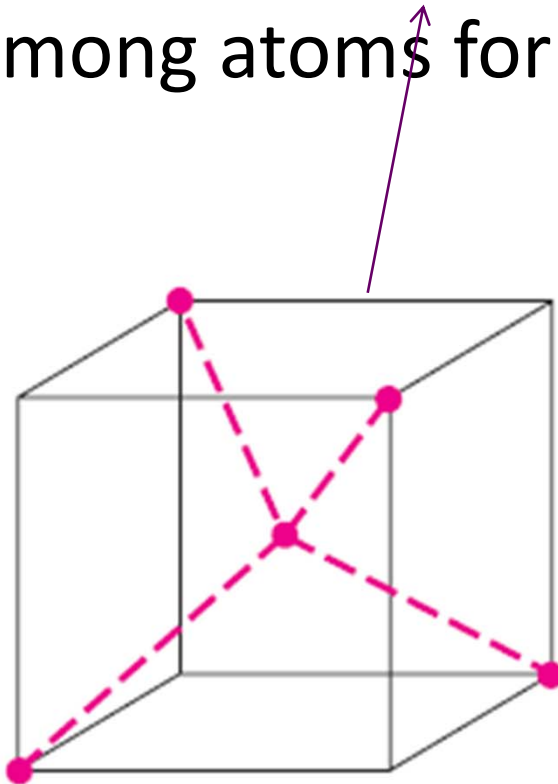
Silicon is a well known intrinsic semiconductor

Five noninteracting Silicon atoms:

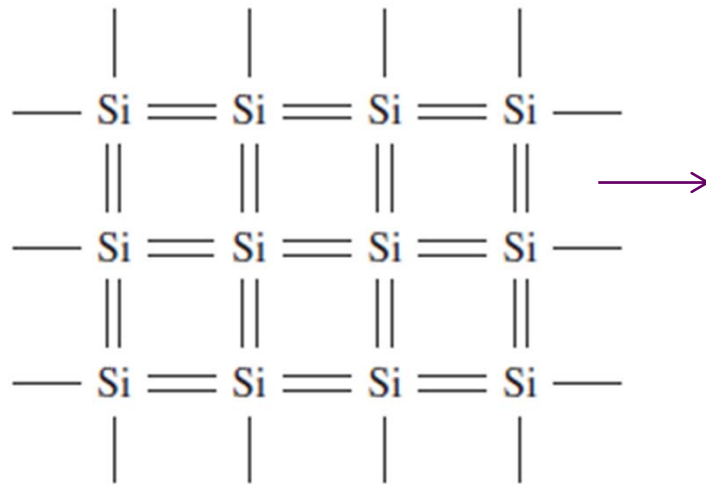


When Silicon atoms come into close proximity of each other the **valence electrons interact** to form **crystal**.

The crystal is **tetrahedral** and valence electrons are **shared** among atoms forming **covalent bonds**.



→ More?? Yes!

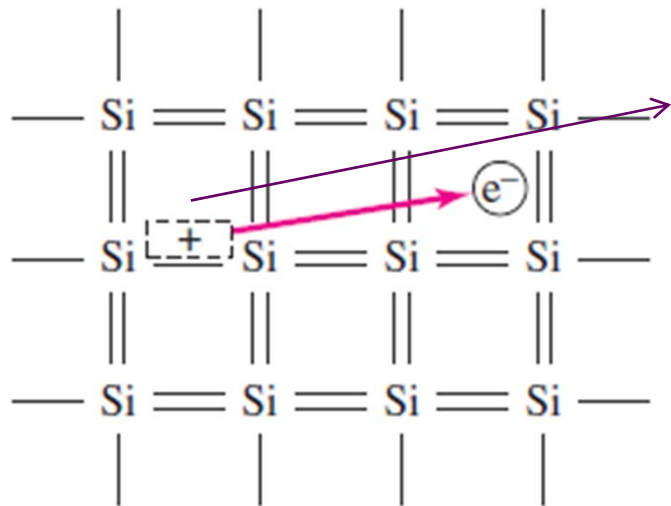


2D representation of Silicon crystal at 0 Kelvin temperature.

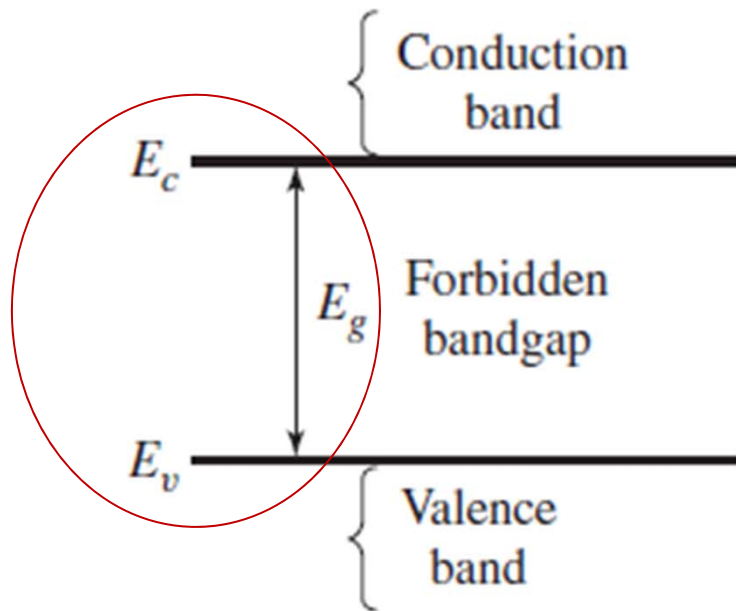
At 0 Kelvin, the valence electrons are at its **lowest possible energy** held in covalent bond

There is no electron free of the bond and electrons will not move. So at **0 K Silicon is an insulator.**

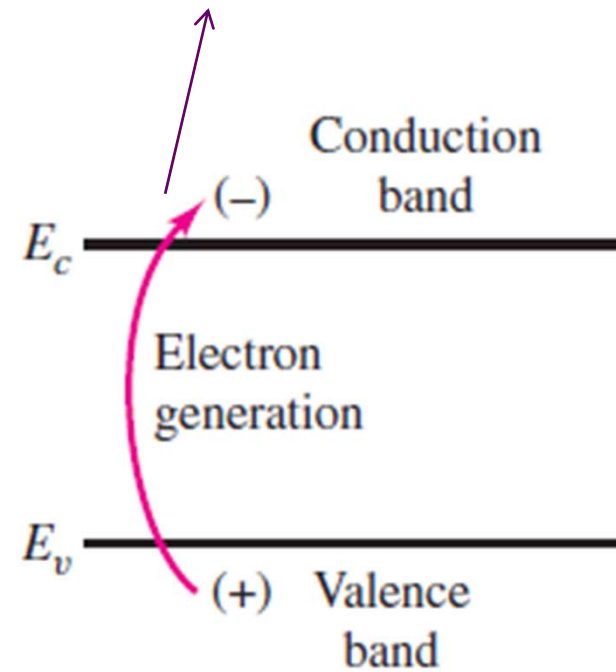
- Silicon in 0 K crystal form has electrons that occupy some allowed **energy bands**. Among them the **valence electrons** occupy the **valence energy band**.
- If the **temperature rises**, the valence electrons can gain enough **thermal energy** to **break** the **covalence bond** and move.
- The valence electrons need to gain a minimum energy called the **bandgap energy** for the above to happen. After absorbing the energy the electrons now exist in **conduction band**.



Positively charged empty state



Energy gain



Materials –

- Large bandgap 3 to 6 eVs (@ 0 K) are insulators, no free electron at room temperature.
- Large number of free electrons (@ 0 K) in the conduction band are conductors at room temperature.
- In a semiconductor the bandgap is of the order of 1eV (@ 0 K).

The net charge of a semiconductor is zero. Negative free electrons and positive “empty” state.

A list of some semiconductor materials

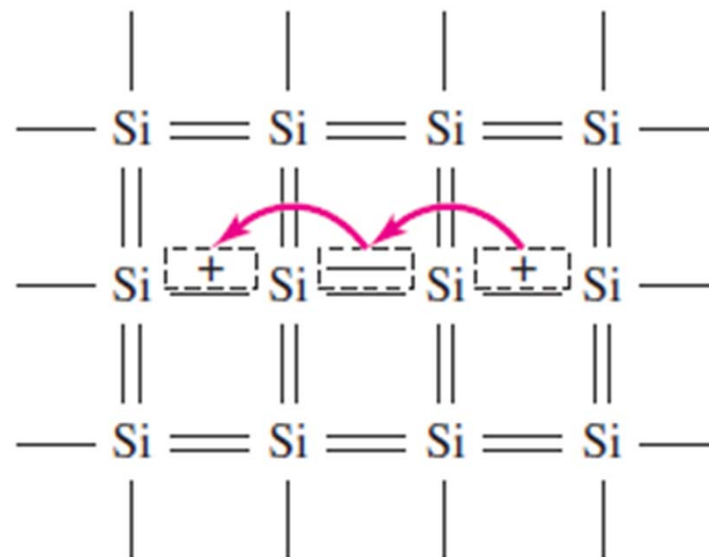
Elemental semiconductors		Compound semiconductors	
Si	Silicon	GaAs	Gallium arsenide
Ge	Germanium	GaP	Gallium phosphide
		AlP	Aluminum phosphide
		AlAs	Aluminum arsenide
		InP	Indium phosphide

A portion of the periodic table

III	IV	V
5 B Boron	6 C Carbon	
13 Al Aluminum	14 Si Silicon	15 P Phosphorus
31 Ga Gallium	32 Ge Germanium	33 As Arsenic
49 In Indium		51 Sb Antimony

Group IV
(transitional metal)
Group III & V
together

- As the **temperature increases**, more covalent bonds are broken, and more **free electrons** and **positive empty states** are created.
- A valence electron acquiring thermal energy can move to adjacent empty state. This movement of a **negatively charged electron** also signifies the movement of **positively charged "hole"**.



In semiconductors, then, **two types of charged particles** contribute to the current:

- **The negatively charged free electron**
- **The positively charged hole**

Concentration of **electrons** and **holes** are important parameters related to the magnitude of the current

Intrinsic semiconductor -

- Has no other types of atom
- Thermally generated electrons and holes are only source of such particles.

So intrinsic carrier concentration of free electrons is same as holes.


$$n_i = BT^{3/2}e^{\left(\frac{-E_g}{2kT}\right)}$$

B - Specific to a semiconductor material

k - Boltzmann's constant

T - Temperature in K

E_g - Bandgap energy

- The bandgap energy E_g and coefficient B are not strong functions of temperature.
- The intrinsic concentration is a parameter used in current–voltage equations for semiconductor devices.

Semiconductor constants		
Material	E_g (eV)	B (cm ⁻³ K ^{-3/2})
Silicon (Si)	1.1	5.23×10^{15}
Gallium arsenide (GaAs)	1.4	2.10×10^{14}
Germanium (Ge)	0.66	1.66×10^{15}

Issue:

Concentration of electrons and holes in intrinsic semiconductors are less and suitable for carrying only **small currents**.

Extrinsic Semiconductor:

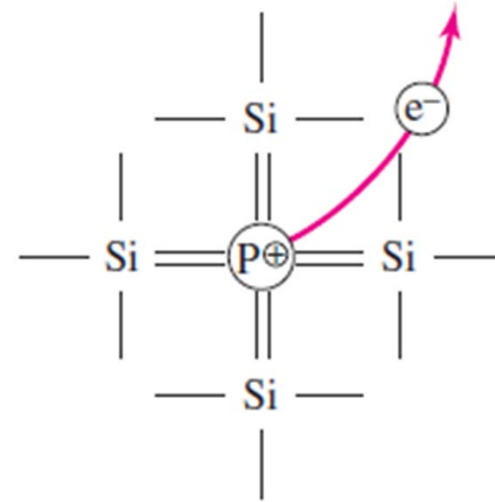
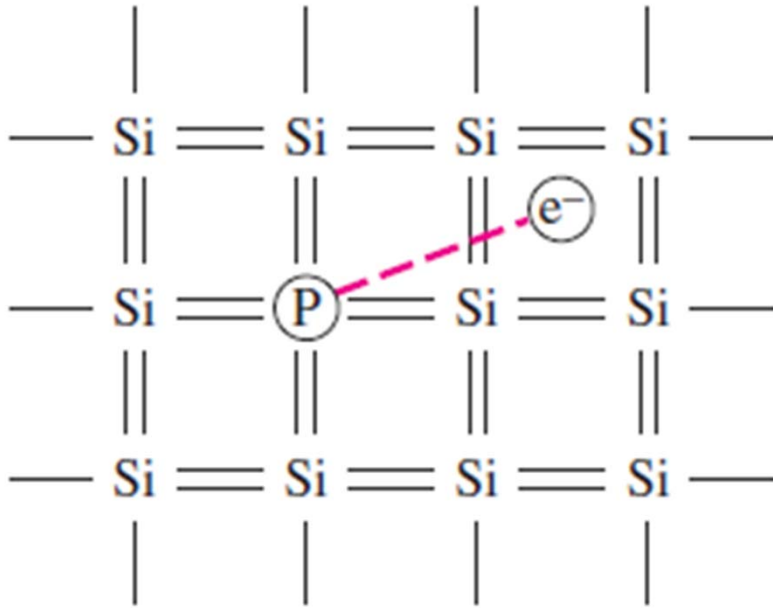
- Electron / hole **concentration** can be hugely **increased (controlled)** by adding controlled amount of impurities.
- **Desired impurity** is one that enters the crystal lattice and **replaces one of the semiconductor atom**. Most preferred are the **Phosphorous (Group III)** or **Boron (Group V)** elements.

Phosphorous Impurity –

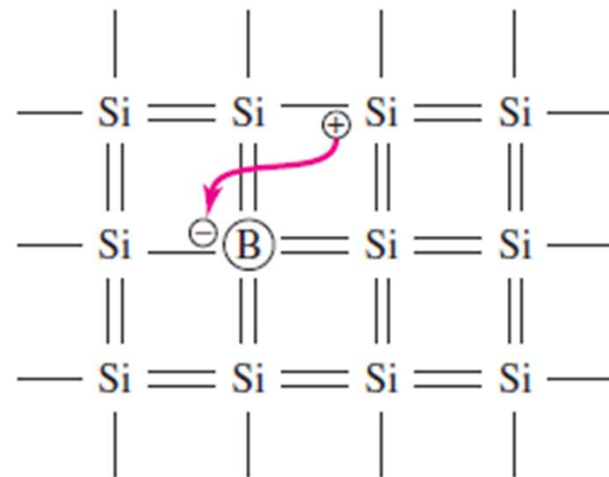
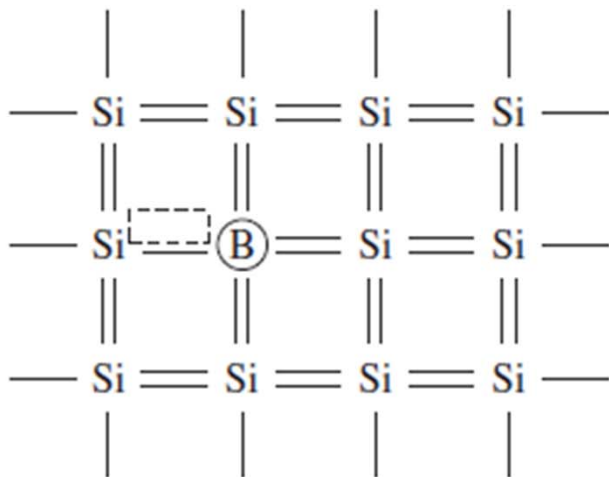
- 4 valence electrons of Phosphorous atom forms covalent bonds with that of Silicon, whereas the 5th one is loosely bound.
- The 5th electron is already in the conduction band.
- When the 5th electron moves to conduction band, a positively charge Phosphorous ion is created but no hole is created!

Phosphorous Impurity –

- The phosphorus atom is called a **donor impurity**, since it **donates an electron** that is free to move.
- A semiconductor that contains **donor impurity** atoms is called an **n-type semiconductor**.
- This process of generation of free electrons without generating a hole is called **doping**.



Boron Impurity – ?



Boron Impurity –

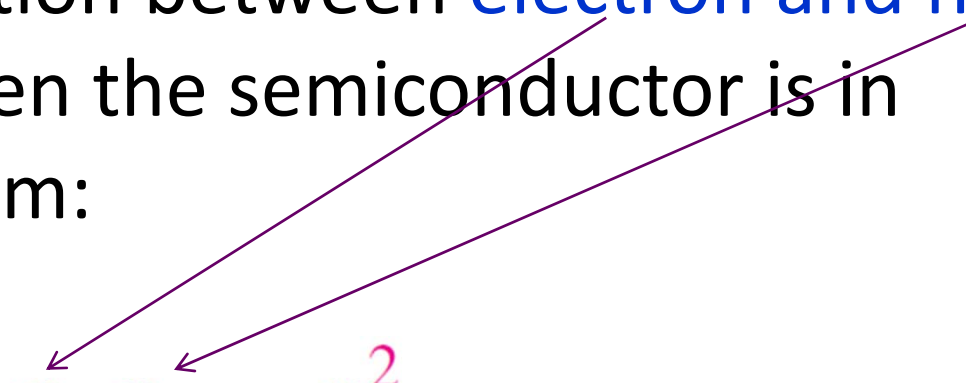
- 3 valence electrons of Boron atom forms covalent bonds with that of Silicon, whereas 1 Silicon electron is loosely bound.
- Another electron from nearby silicon atom moves to make the 4th covalent bond, at room temperature.
- A Hole is created. The Boron atom has a net negative charge, but no electron is free.

Boron Impurity –

- The Boron atom is called an **acceptor impurity**, since it **accepts an electron** and a hole is **created**.
- A semiconductor that contains **acceptor impurity atoms** is called an **p-type semiconductor**.
- This process of generation of holes without generating a electrons is also called **doping**.

- Materials containing impurity atoms are called **extrinsic semiconductors**, or **doped semiconductors**.
- Doping process allows us **to control the concentration** of free electrons and holes.

Fundamental relation between **electron and hole concentration** when the semiconductor is in thermal equilibrium:


$$n_o p_o = n_i^2$$

At room temperature ($T=300\text{K}$), each donor / acceptor atom donates / accepts an electron. If the donor / acceptor concentration is assumed much higher than the intrinsic one we have:

$$p_o = \frac{n_i^2}{N_d} \longrightarrow \text{Donor impurity}$$

$$n_o = \frac{n_i^2}{N_a} \longrightarrow \text{Acceptor impurity}$$

Holes or electrons whose concentration is higher (lower) is called the majority (minority) carrier